



US00D785577S

(12) **United States Design Patent** (10) **Patent No.:** **US D785,577 S**  
**Kawase** (45) **Date of Patent:** **\*\* May 2, 2017**

- (54) **SEMICONDUCTOR DEVICE**
- (71) Applicant: **Mitsubishi Electric Corporation**, Tokyo (JP)
- (72) Inventor: **Tatsuya Kawase**, Chiyoda-ku (JP)
- (73) Assignee: **Mitsubishi Electric Corporation**, Tokyo (JP)
- (\*\*) Term: **15 Years**
- (21) Appl. No.: **29/555,470**
- (22) Filed: **Feb. 22, 2016**

**Related U.S. Application Data**

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(30) **Foreign Application Priority Data**

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- Aug. 21, 2013 (JP) ..... 2013-019057

- (51) **LOC (10) Cl.** ..... **13-03**

- (52) **U.S. Cl.**  
USPC ..... **D13/182**

(58) **Field of Classification Search**

- USPC ..... D13/110, 182; 257/678, 684, 690, 691; 361/679.01, 713, 728, 736, 760, 761, 772, 361/775, 783, 820; 174/250, 253; 438/15, 25, 26, 51, 55, 63, 64, 106
- CPC . H01L 21/00; H01L 2224/42; H01L 2224/43; H01L 2021/00; H01L 2021/02; H01L 2021/04; H01L 21/4814; H01L 21/4846; H01L 21/4871; H01L 21/67144; H01L 23/12; H01L 23/13; H01L 23/14; H01L 23/147; H01L 2924/171; H01L 2924/1711; H01L 2924/1715; H01L 2924/17151; H01L 2924/181; H01L

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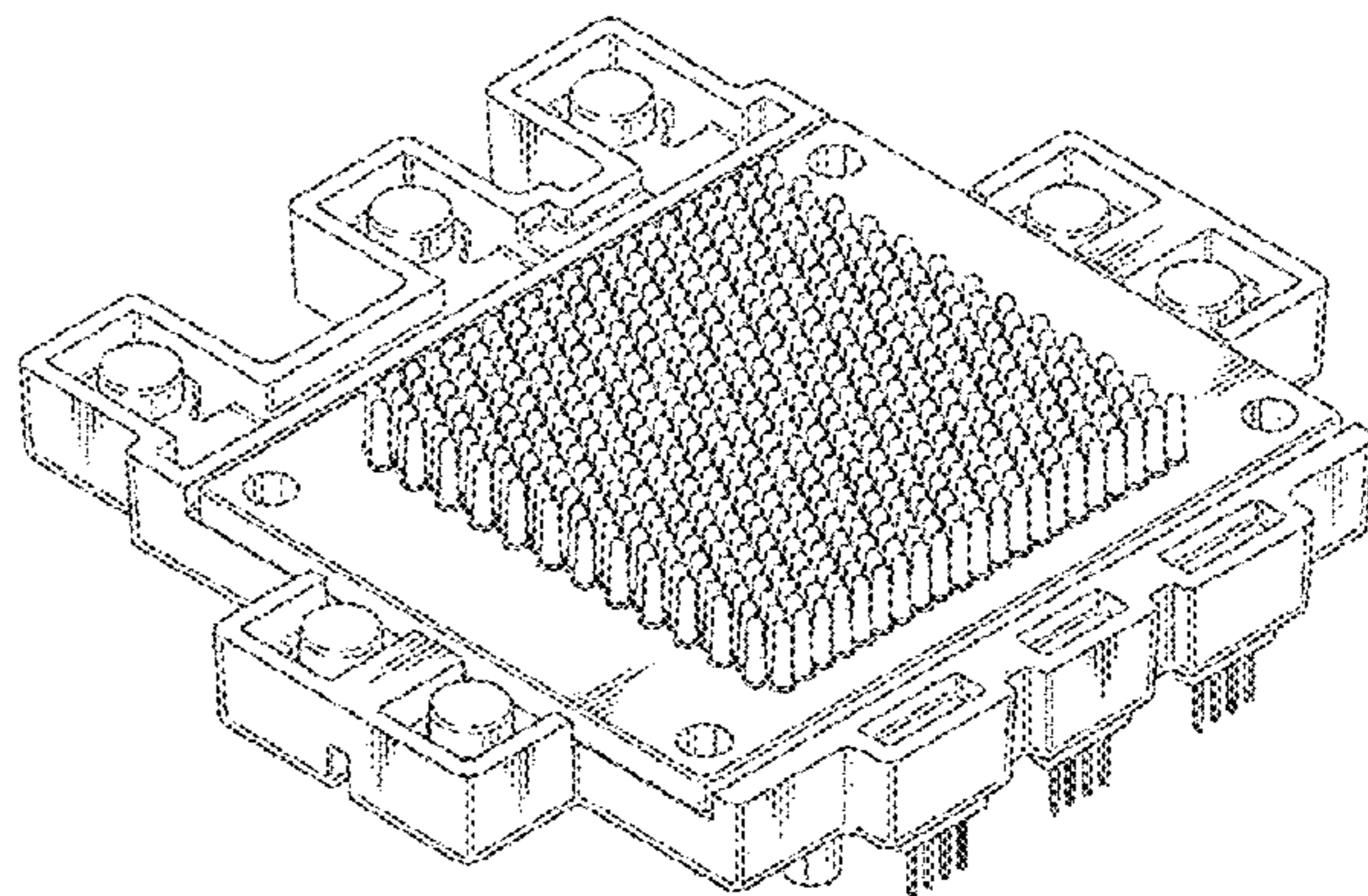
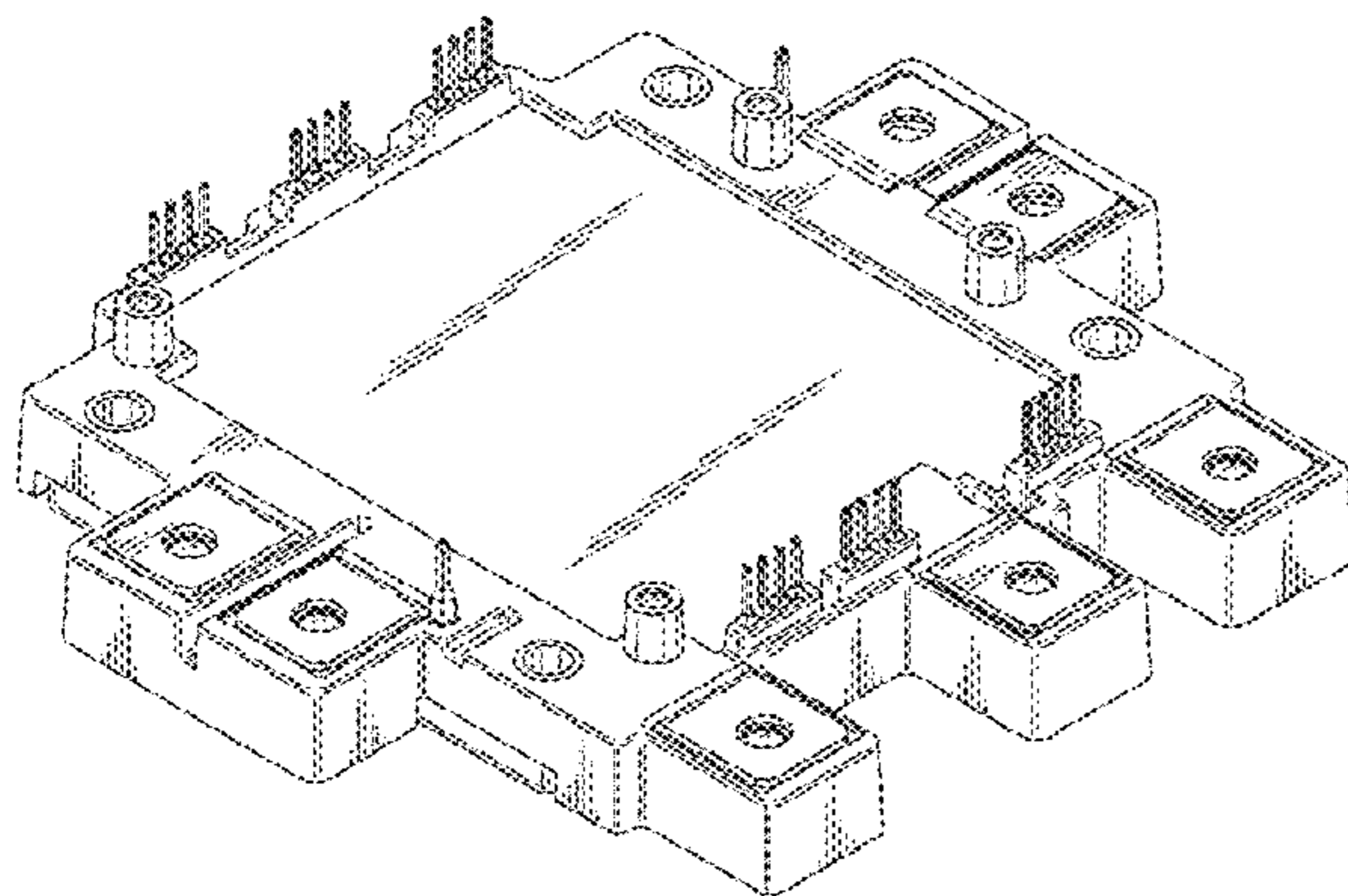
(57) **CLAIM**

The ornamental design for a semiconductor device, as shown and described.

**DESCRIPTION**

FIG. 1 is a top, right and rear side perspective view of a semiconductor device, showing my new design;  
 FIG. 2 is a front, left and bottom side perspective view thereof;  
 FIG. 3 is a front elevational view thereof;  
 FIG. 4 is a rear elevational view thereof;  
 FIG. 5 is a left side elevational view thereof;  
 FIG. 6 is a right side elevational view thereof;  
 FIG. 7 is a top plan view thereof;  
 FIG. 8 is a bottom plan view thereof;  
 FIG. 9 is another perspective view thereof, shown in a used condition mounted to a board in broken lines; and,  
 FIG. 10 is another rear elevational view thereof, shown in a used condition mounted to a board in broken lines.  
 The broken lines shown in the drawings represent portions of the semiconductor device, that form no part of the claimed design.

**1 Claim, 8 Drawing Sheets**



(58) **Field of Classification Search**  
 CPC ..... 2924/1811; H01L 2924/1815; H01L  
 2924/19042; H01L 2224/08054; H01L  
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 See application file for complete search history.

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Fig. 1

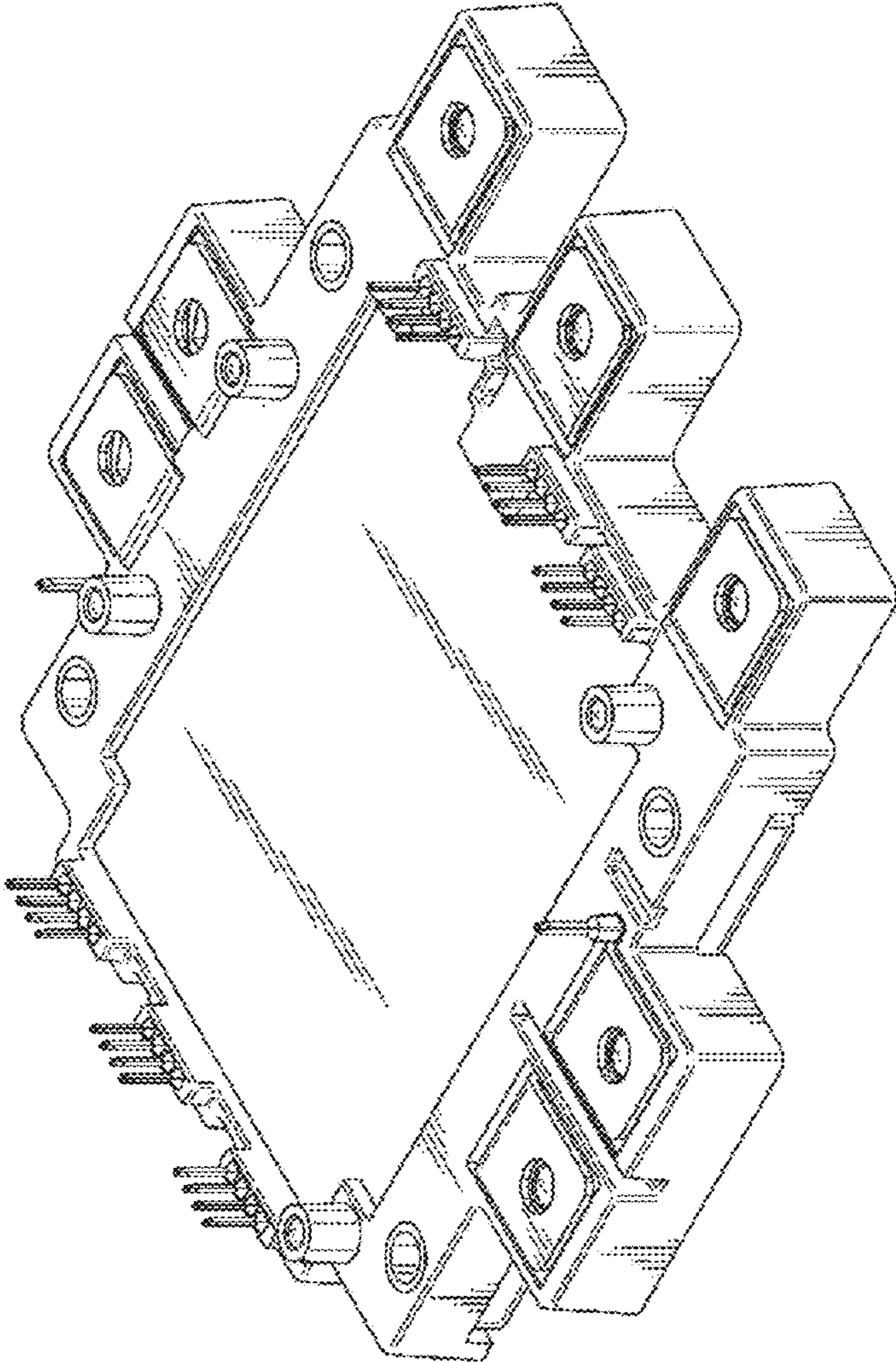


Fig. 2

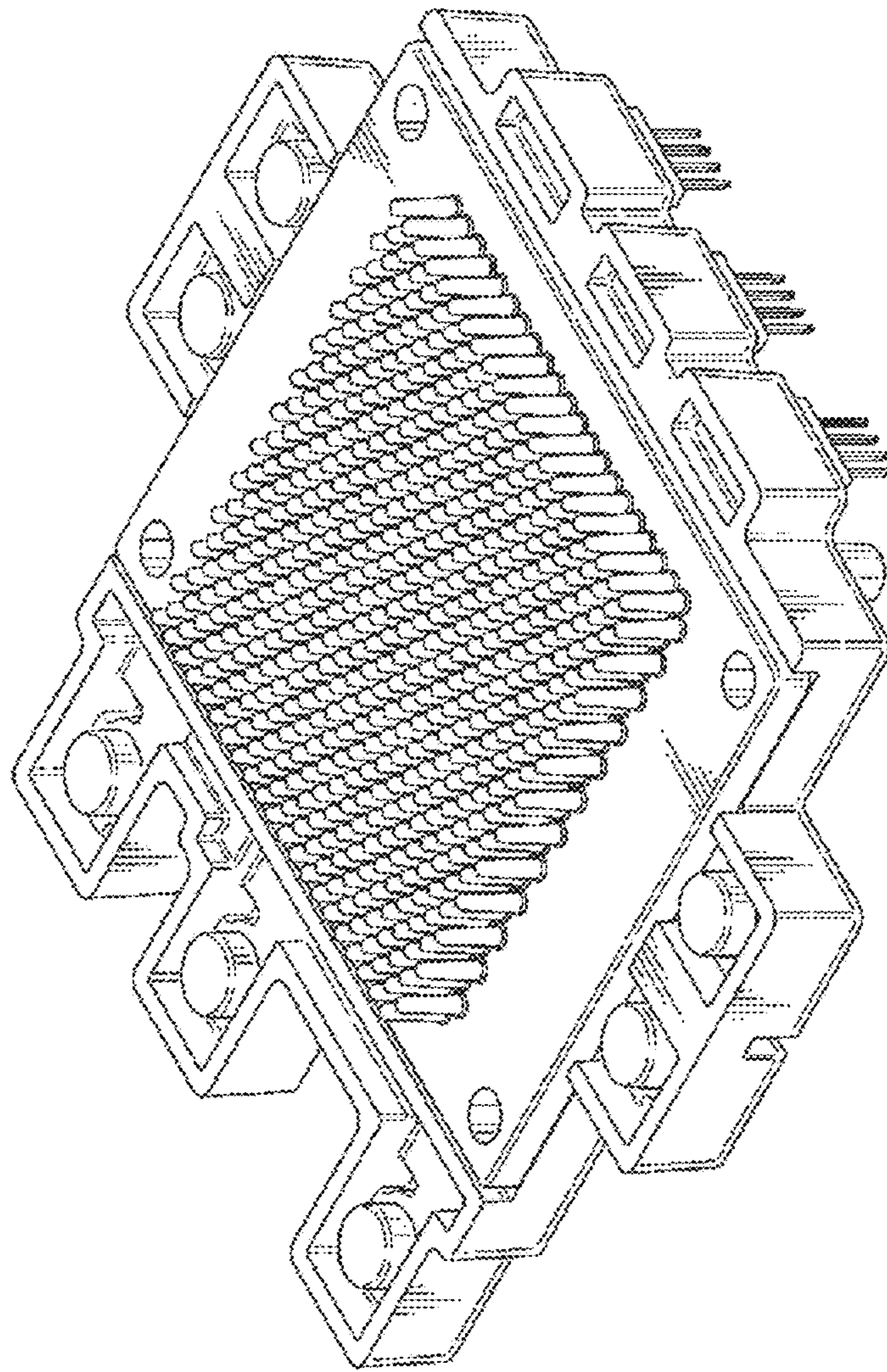


Fig. 3

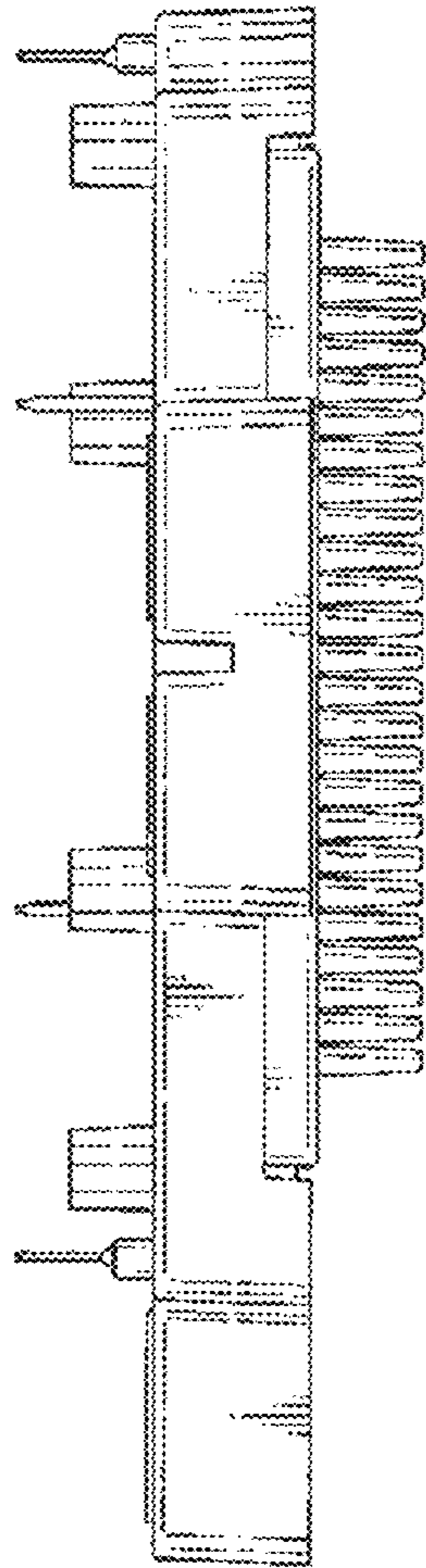


Fig. 4

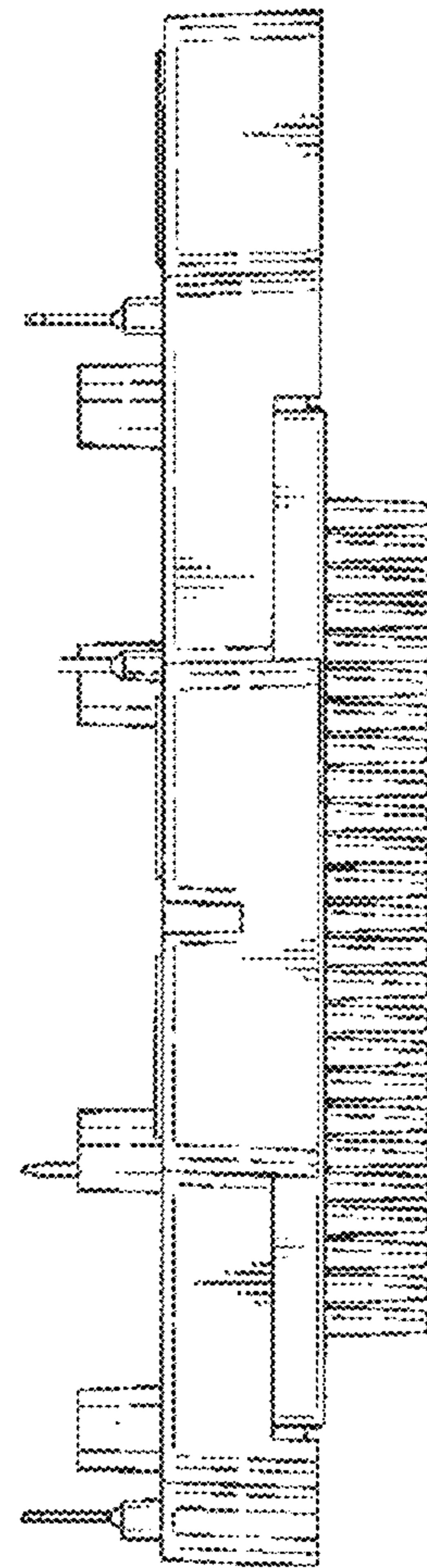


Fig. 5

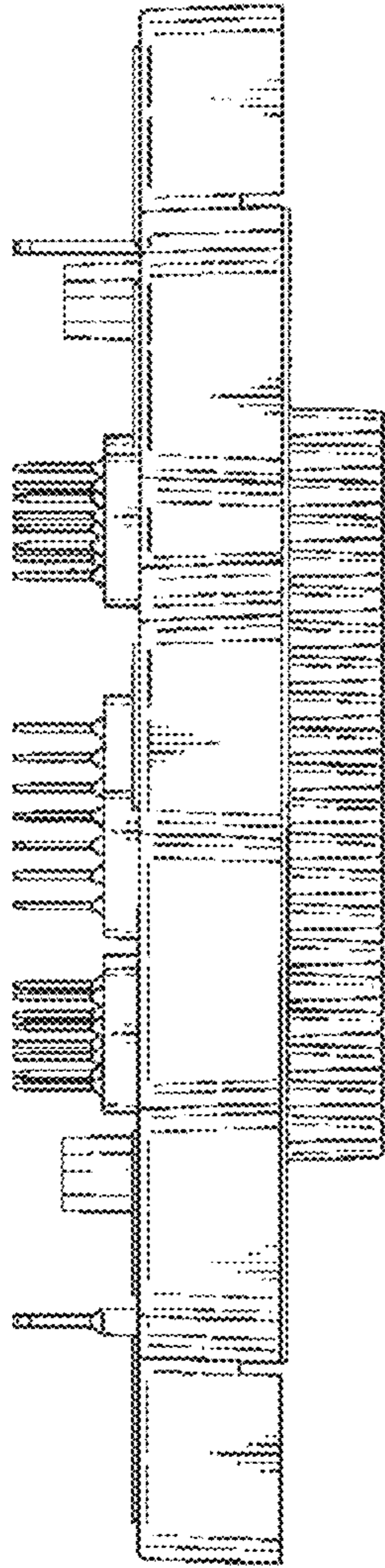


Fig. 6

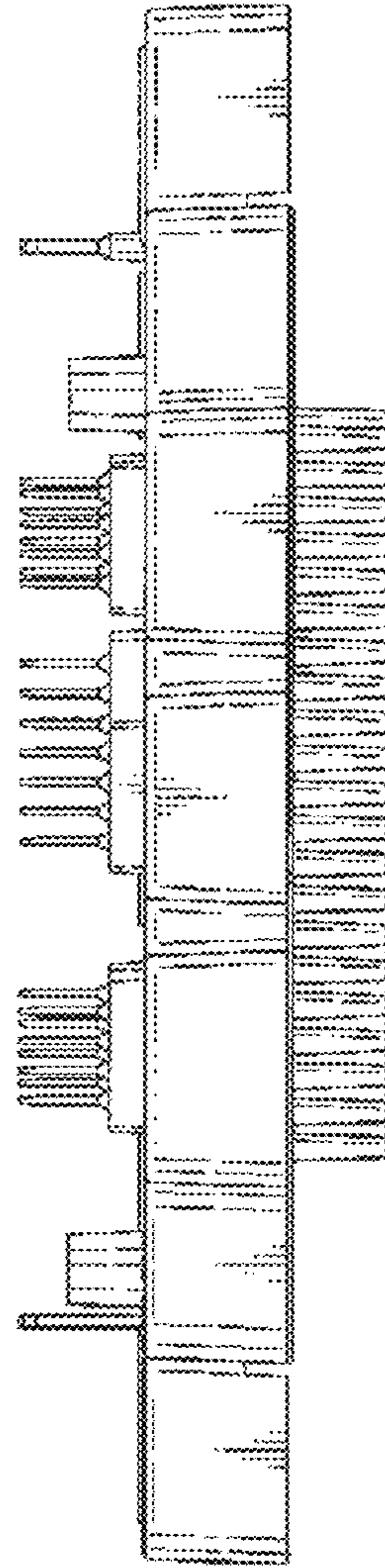


Fig. 7

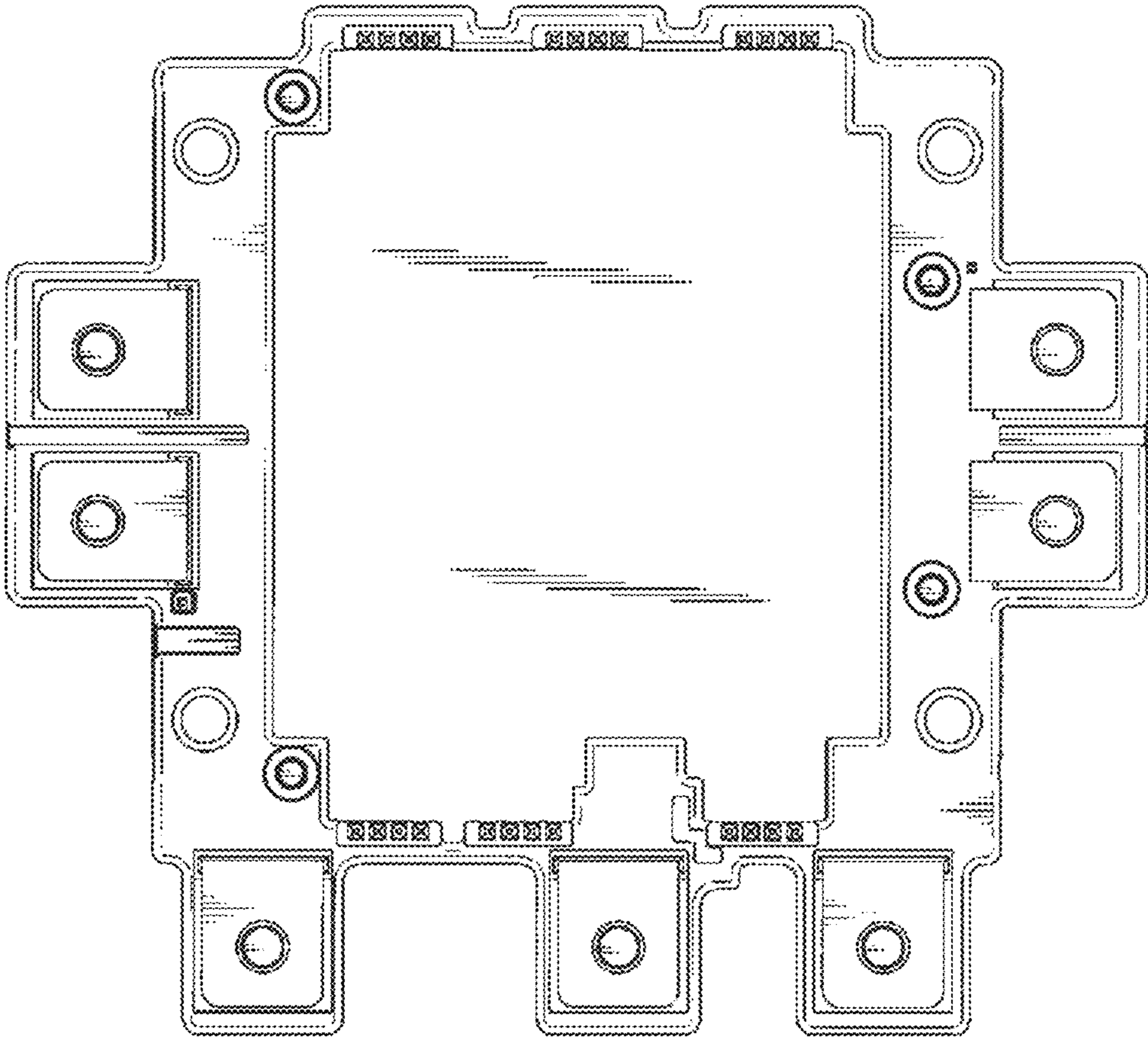


Fig. 8

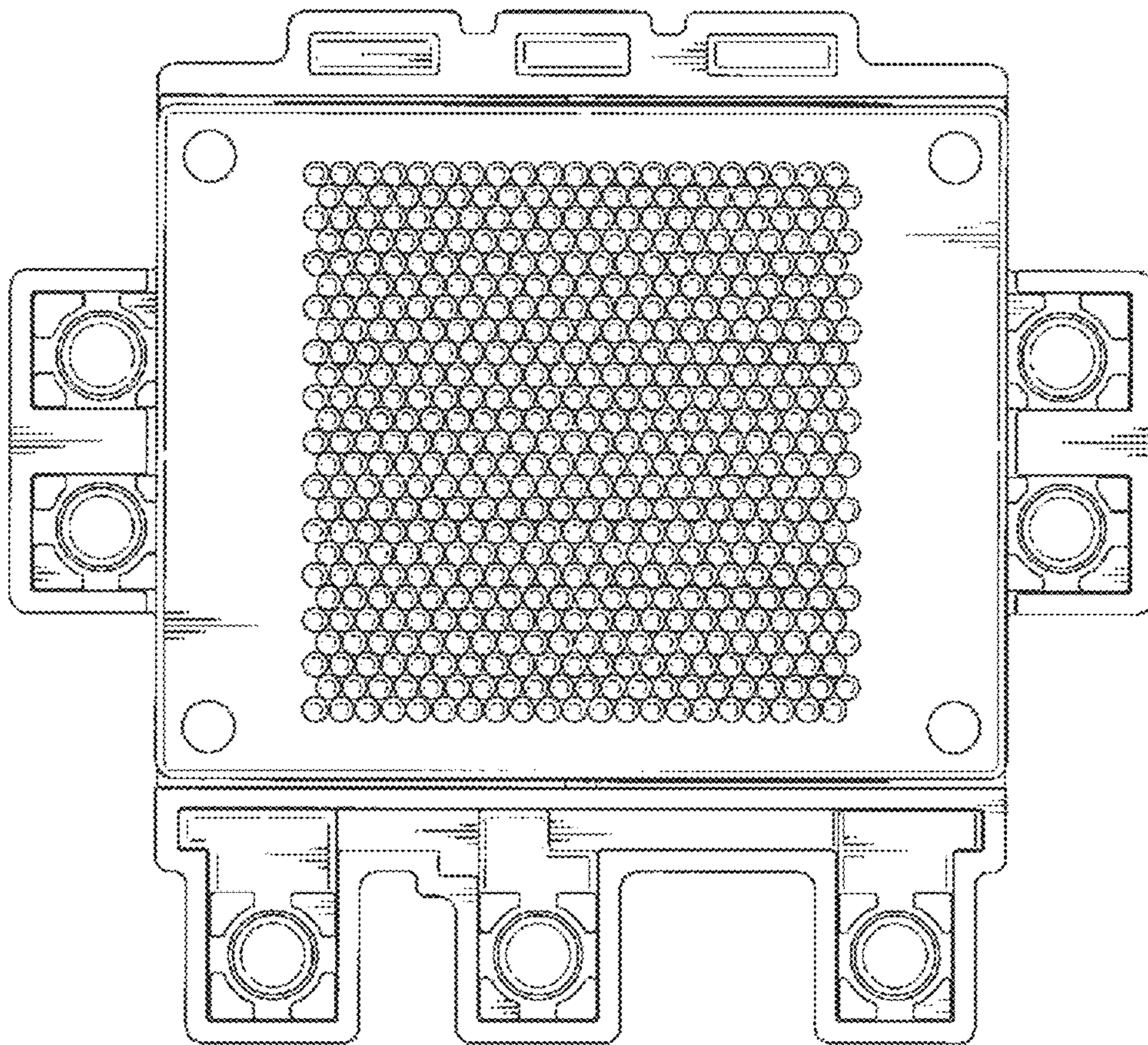




Fig. 9

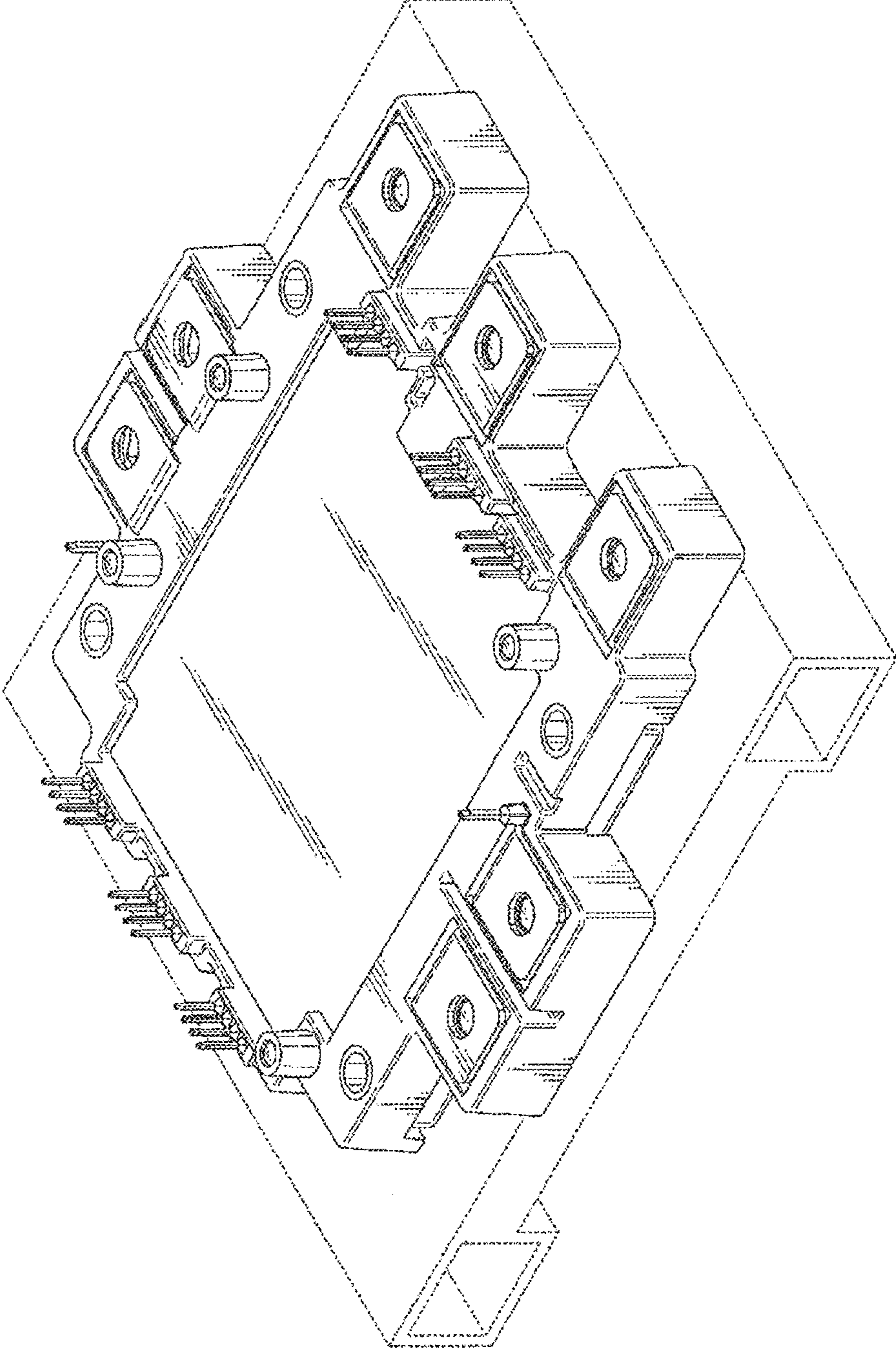


Fig. 10

